EPIPHY GROUP **Epitaxy and Physics of Heterostructures**

lemn Institut d'Electronique, de Microélectronique et de Nanotechnologie **UMR CNRS 8520**

Permanent researchers : Djamila Hourlier (DR CNRS), Ludovic Desplanque (MCF), Dominique Vignaud (CR CNRS) and Xavier Wallart (DR CNRS) Engineer: C.Coinon Post-doc: Walter Batista Pessoa

PhD Students: Wijden Khelifi, Jawad Hadid

Main thematics

General objectives

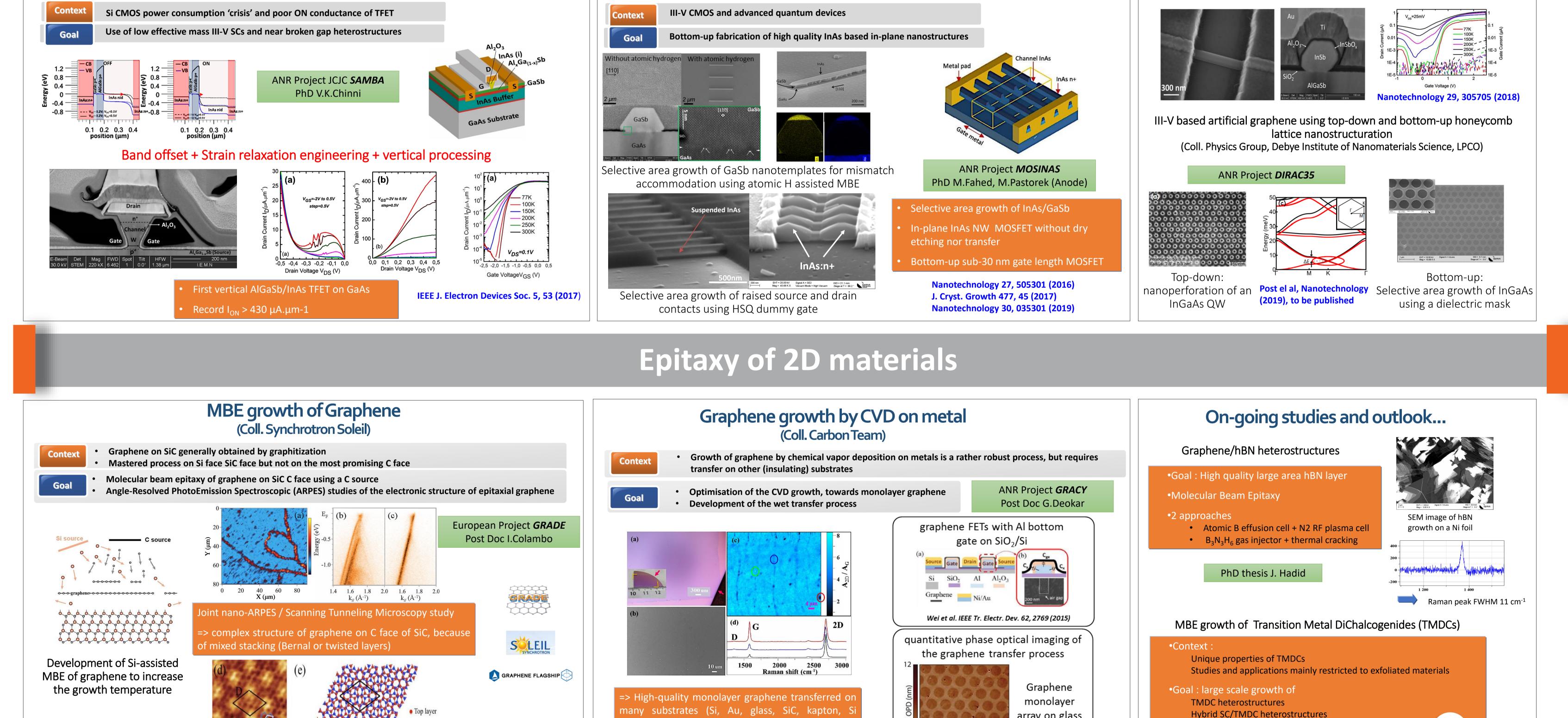
Elaboration and characterization of (nano)materials for high frequency, low power applications and advanced devices:

- III- V semiconductors : 2D heterostructures and nanostructures
- 2D materials : graphene epitaxy on SiC and metals hBN epitaxy -Transition Metal Dichalcogenides (TMDC)
- Organic-inorganic composite nanomaterials

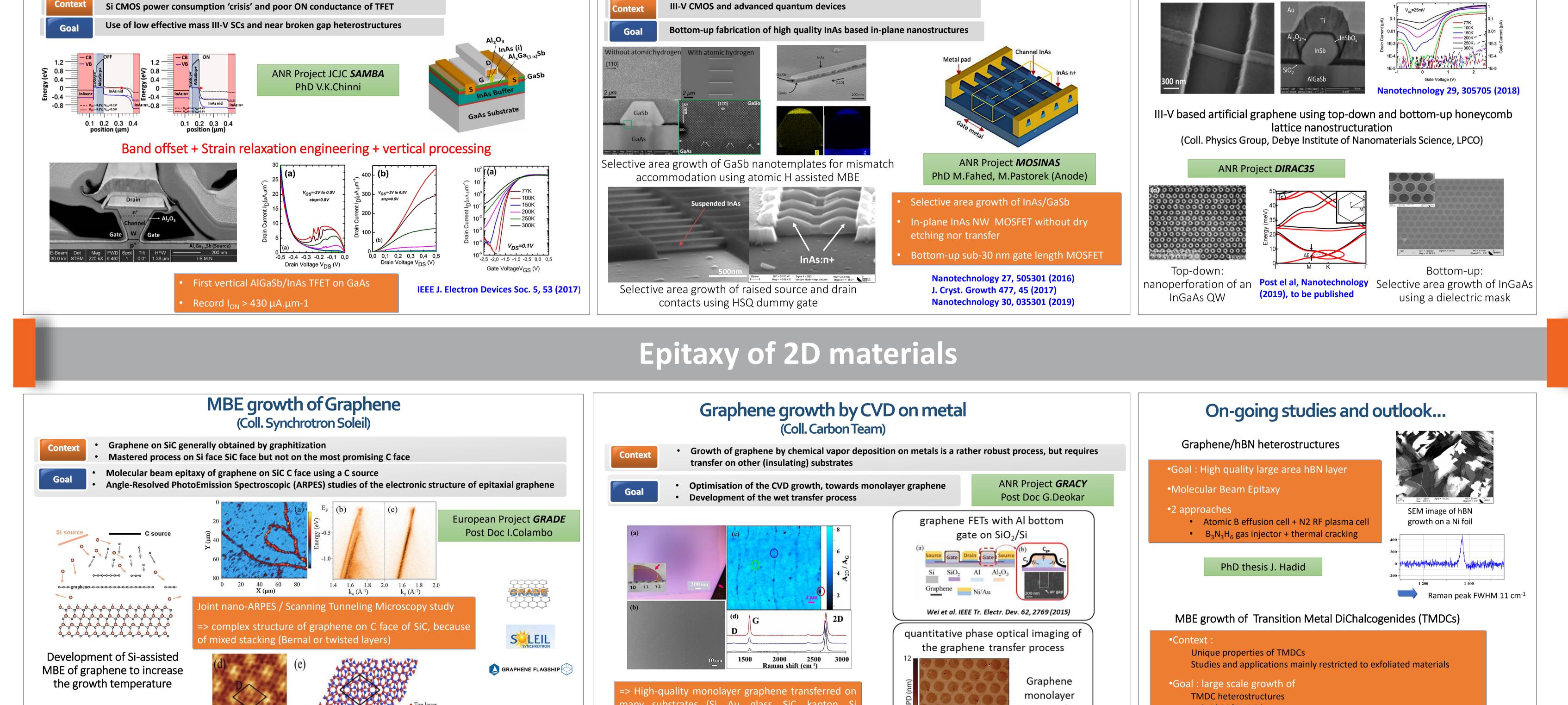
- Growth of controlled structures for device purposes
- Understanding growth mechanisms
- Development of new processes or material heterostructures for advanced devices
- In-depth physical and chemical characterization of grown materials

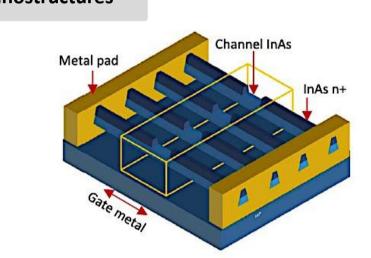
III-V semiconductor epitaxy for advanced electronic devices

Epitaxy of InAs/AlGaSb heterostructures for Tunnel FET (Coll. Anode Group)



Selective area Molecular Beam Epitaxy for InAs Nanowire MOSFET (coll. Anode Group, C2N)





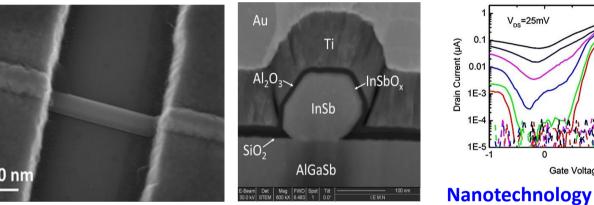
array on glass

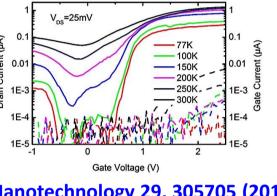
Khadir et al. ACS Phot. 4, 3130 (2017)

FRESNEL

On-going studies and outlook...

Selective Growth and characterization of in-plane InSb NW for spin devices





RENATECH Paras Million Congression Cantonica de Madrinaligues

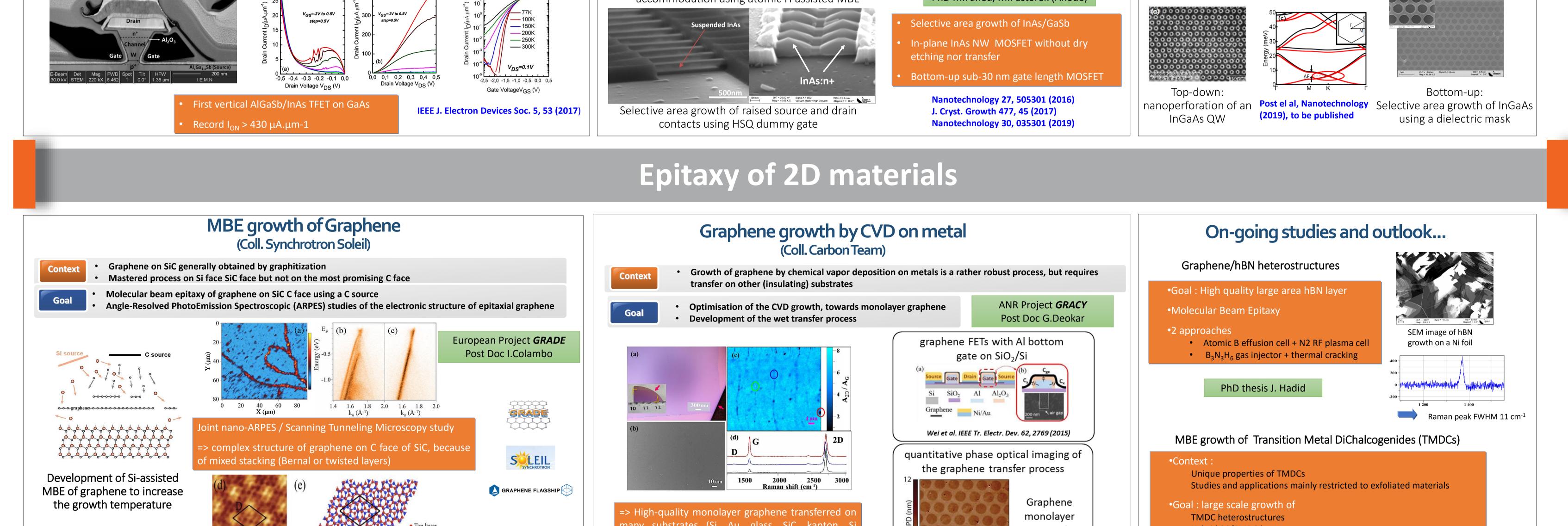
- Commercial absorber - Measur

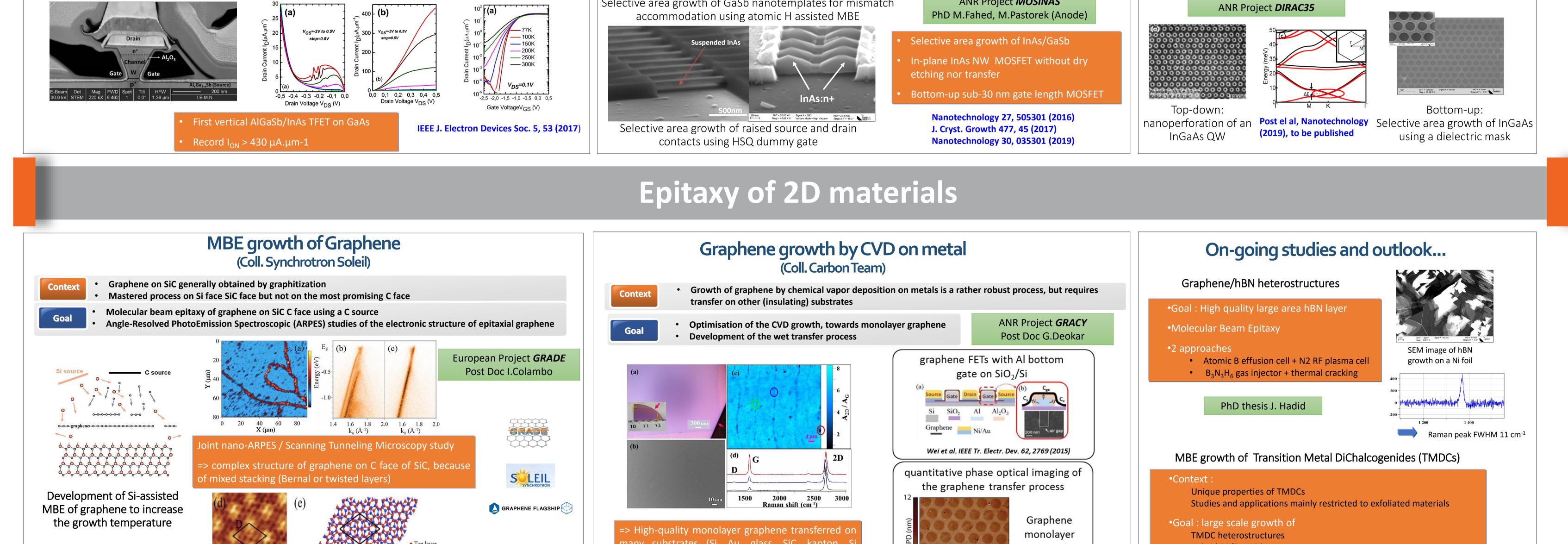
coefficient at normal incidence of



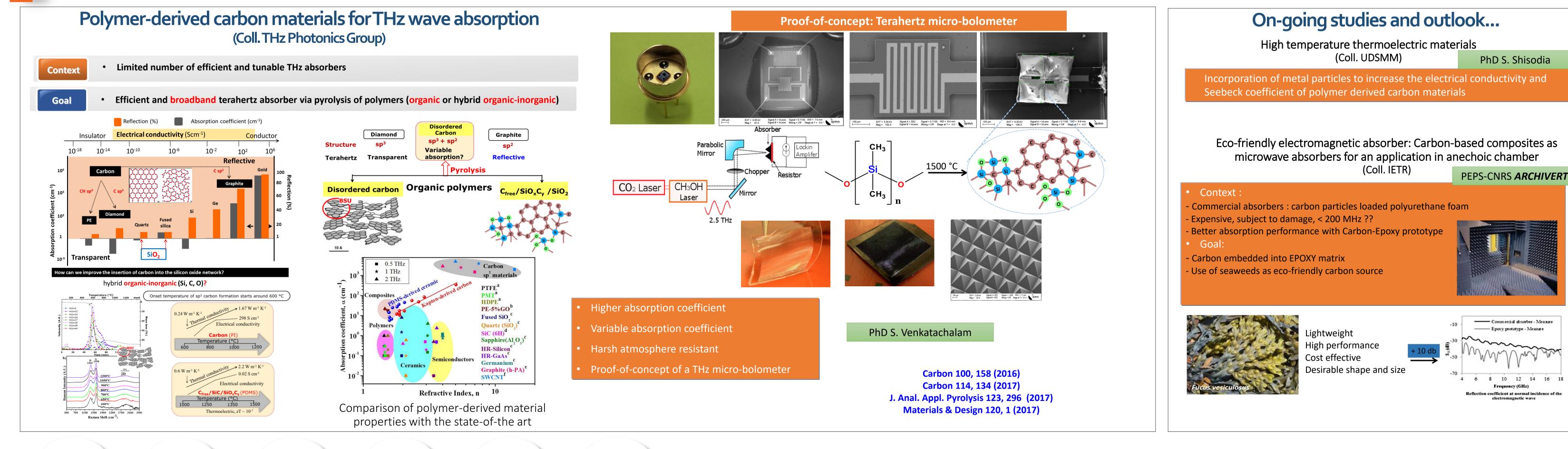
•New MBE reactor (scheduled installation in Fall 2019)

•UHV coupling with a III-V MBE reactor and an ESCA system





Polymer-derived carbon materials



Deokar et al. Carbon 89, 82 (2015)

nanorod array...)

Phys. Rev. B 92, 035105 (2015)

Sci. Rep. 6, 27261 (2016)



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